

## *CALL FOR PAPERS*

The International Conference on Pattern Recognition (ICPR) is the leading event of the International Association for Pattern Recognition, recognized as a top conference in the field. It encompasses a wide range of topics where Pattern Recognition methods are applied in fields including Computer Vision, Machine Learning, Image Processing, Speech and Natural Language Processing, and Sensor Pattern Processing. The 28th ICPR, to be held in 2026, offers an excellent platform for students, academics, and industry researchers to foster new ideas and collaborations.

The conference will cover topics including, but not limited to the following:

- Artificial Intelligence, Pattern Recognition and Machine Learning
- Computer and Robot Vision
- Image, Speech, Signal and Video Processing
- Biometrics and Human Computer Interaction
- Document Analysis and Recognition
- Biomedical Imaging and Bioinformatics

Prospective authors are invited to submit original papers on these topics.

### **Important deadlines:**

- **Paper submission deadline (extended): January 10, 2026, AoE (UTC-12)**
- Author notification: March 31, 2026
- **Camera-ready uploading to Springer: May 4, 2026 - no extension**

### **Submission and Review:**

ICPR-2026 will follow a single-blind review process. Authors **MUST** include their names and affiliations in the manuscript.

### **Paper Format and Length:**

Springer LNCS format with maximum 15 pages (including references, figures, tables) during paper submission. Springer LNCS paper formatting instructions and templates for ICPR-2026 are available in the ICPR-2026 website (<https://icpr2026.org/authors.html>)

Please visit the ICPR-2026 website [icpr2026.org](https://icpr2026.org) for more details.

We look forward to your participation in ICPR-2026 in this wonderful city of Lyon, an easily accessible for an unforgettable conference!

### **General Chairs:**

Jean-Marc Ogier (France), Tin Kam Ho (USA), Cheng-Lin Liu (China), Dan Lopresti (USA)

### **Program Chairs:**

Maria De Marsico (Italy), Frederic Jurie (France), Ingela Nyström (Sweden), Arun Ross (USA), Liang Wang (China)

